

# Digital multimirror devices for precision laser micromachining

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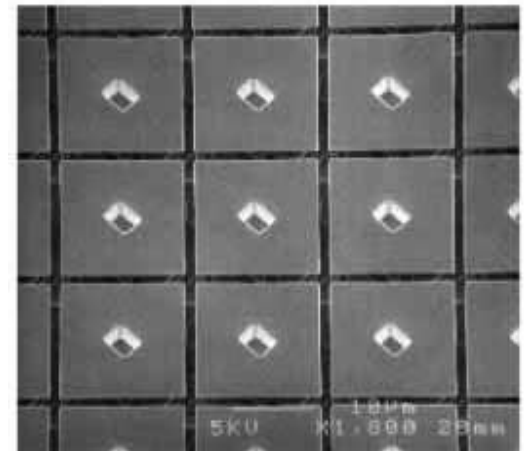
# Content

- **DMD devices for laser processing**
- **Laser:**
  - Ablation
  - Multiphoton polymerisation (MPP)
  - Laser-induced forward transfer (LIFT)
  - *all within the context of **microscale** materials processing*
- **Summary**

# Digital Micromirror Devices (DMD)

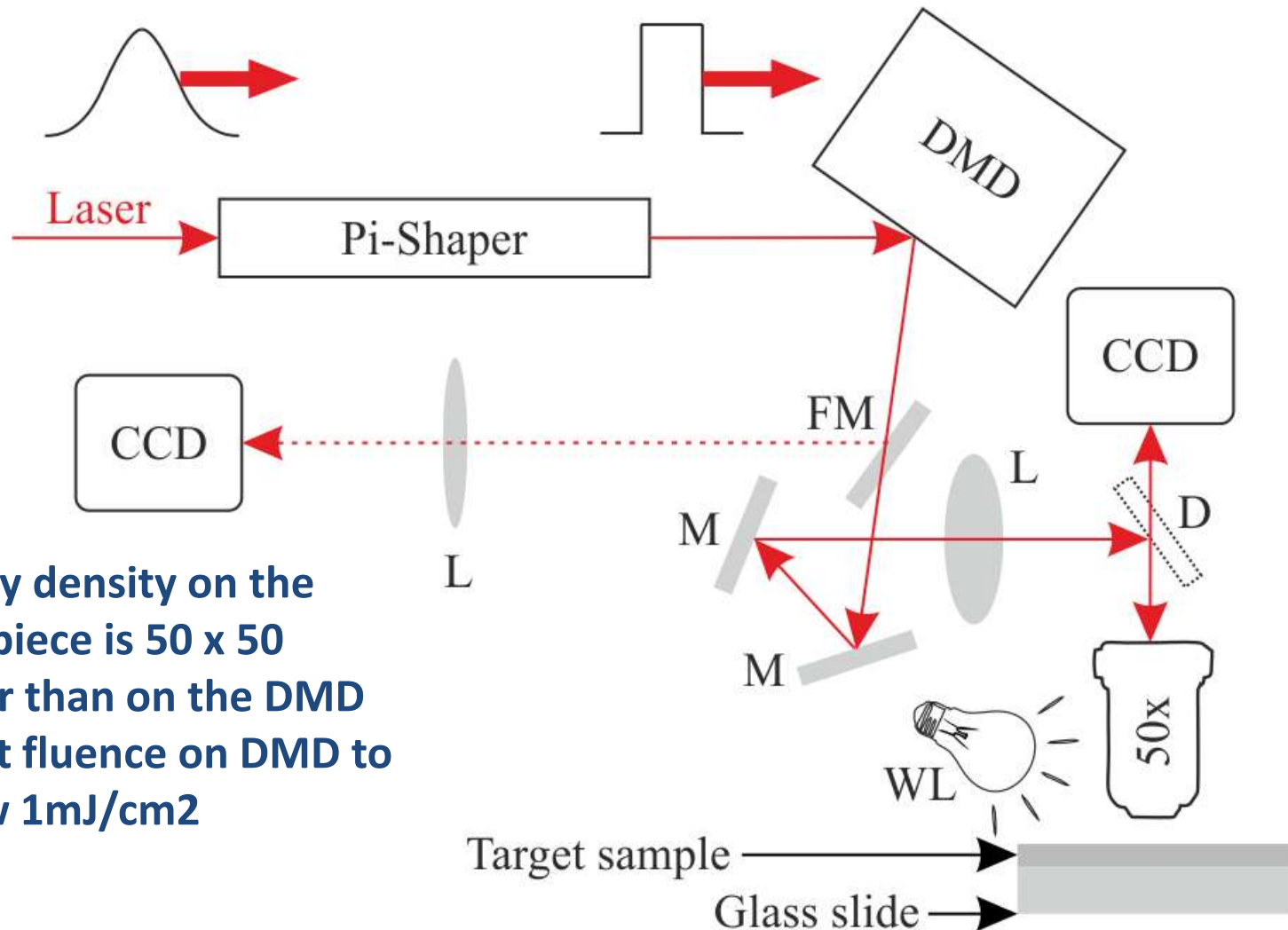
- Used in majority of projectors
- Array of individually controlled  $\sim 7\mu\text{m}$  wide mirrors
- Operates across the visible and NIR region
- Can be used as an *intensity* spatial light modulator (SLM)
- Cheap ( $\sim \text{£}200$ ) and fast switching speed ( $>1\text{KHz}$ )

**Schematic of a section of the digital mirror device (actual model used: Texas Instruments DLP3000, 608 x 684 mirrors)**



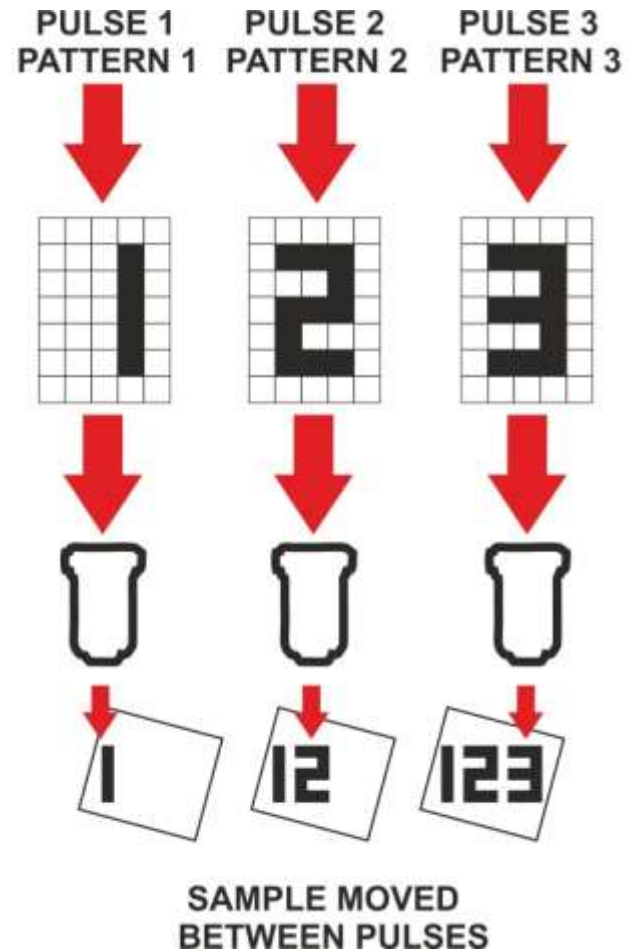
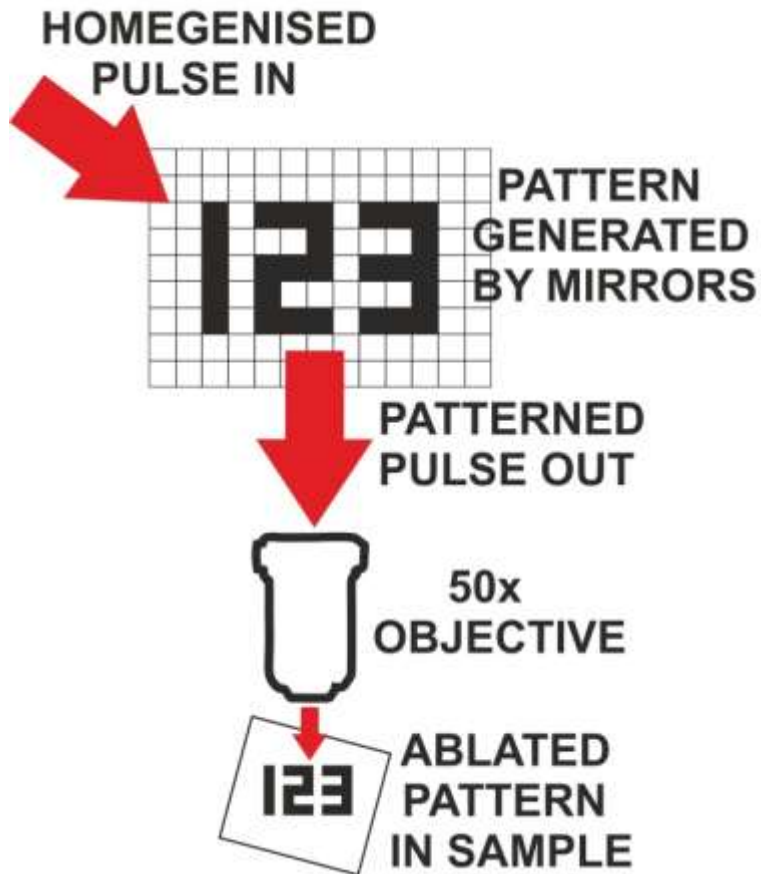
# Experimental schematic

Ti: sapphire, 2mJ max, 1kHz, 800nm



Energy density on the  
workpiece is 50 x 50  
higher than on the DMD  
- Limit fluence on DMD to  
below 1mJ/cm<sup>2</sup>

# Pattern updating

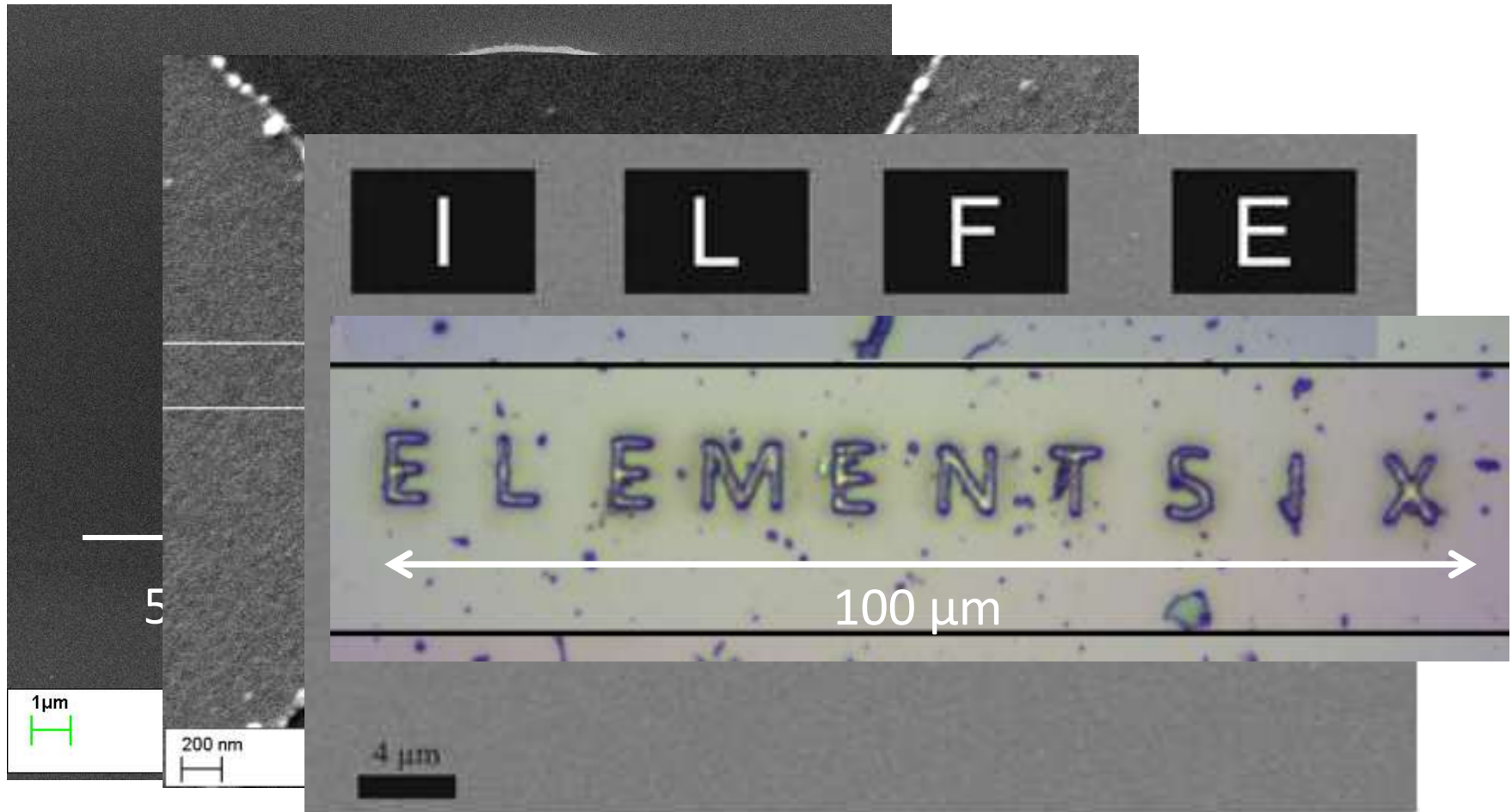


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## 1 Ablative removal:



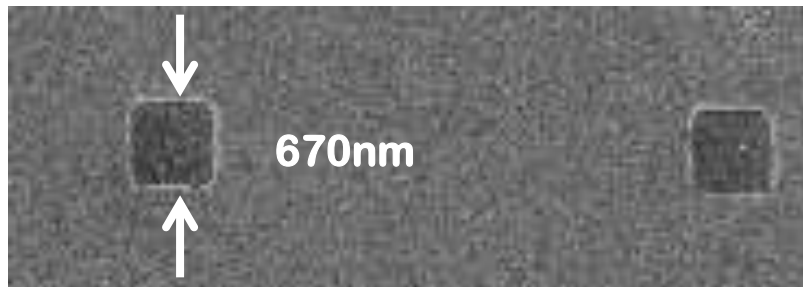
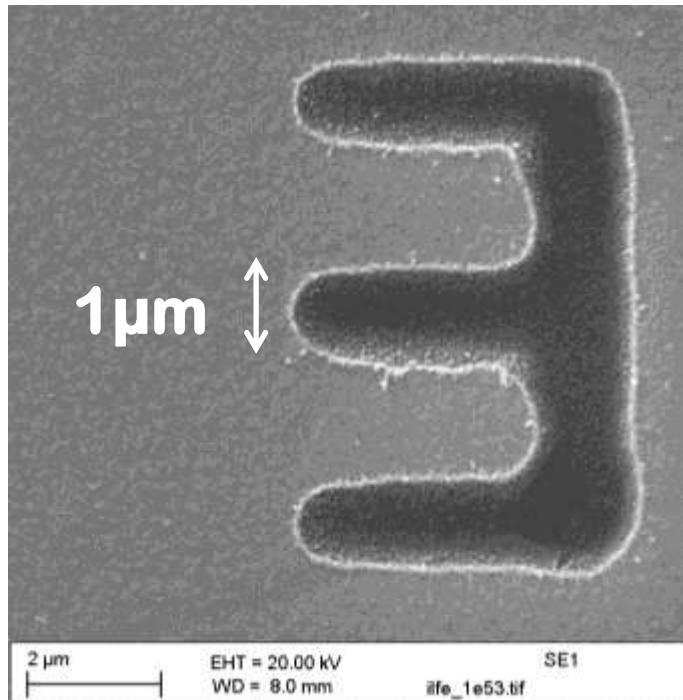
**Semiconductors**

**Metals/alloys**

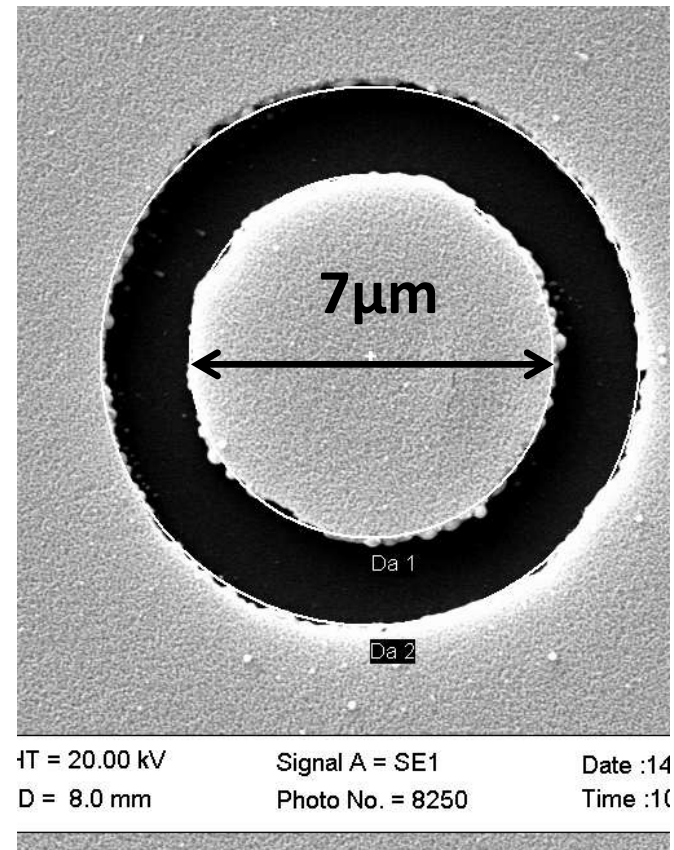
**Diamond**



# Close-ups:



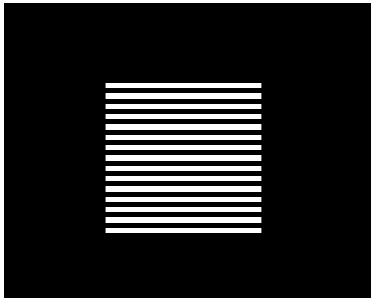
These all took 150 fs





**Direct writing of gratings: 6300 Gratings, Actual time = ~4 minutes, best possible time = 6.3 seconds**

## **How they appear on the DMD**

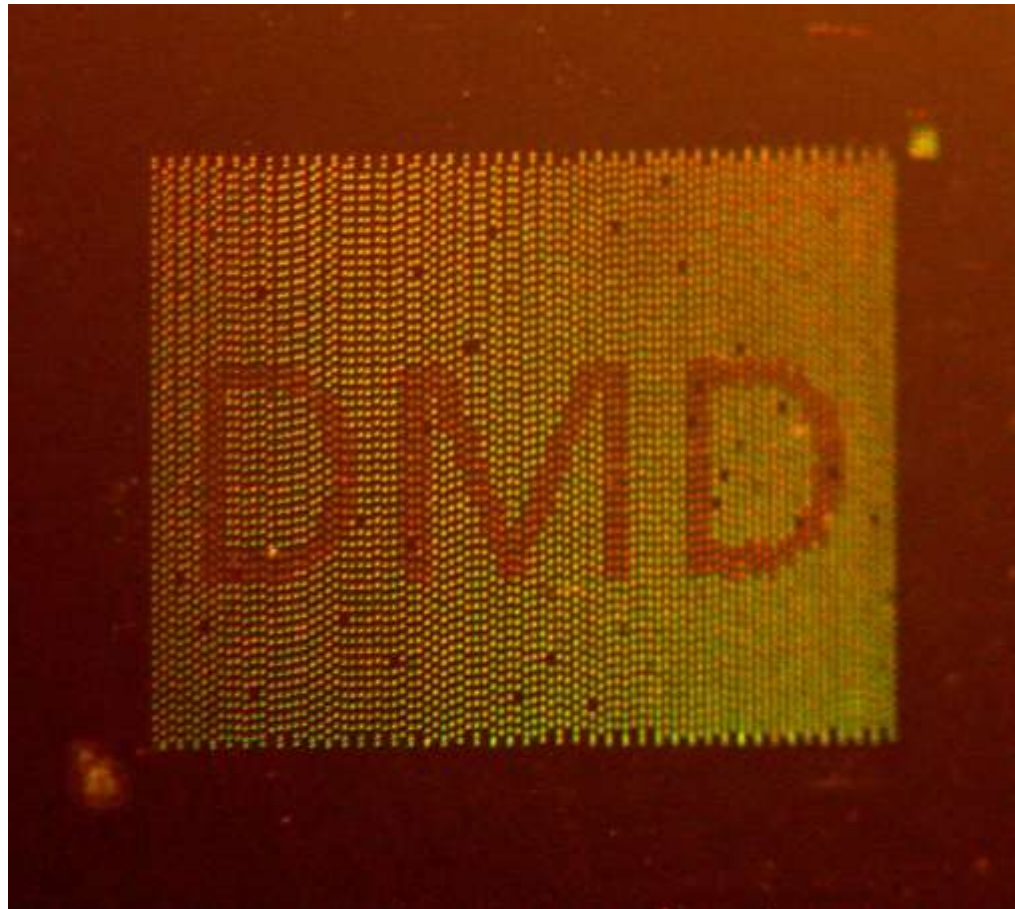


Each line 10 pixels wide



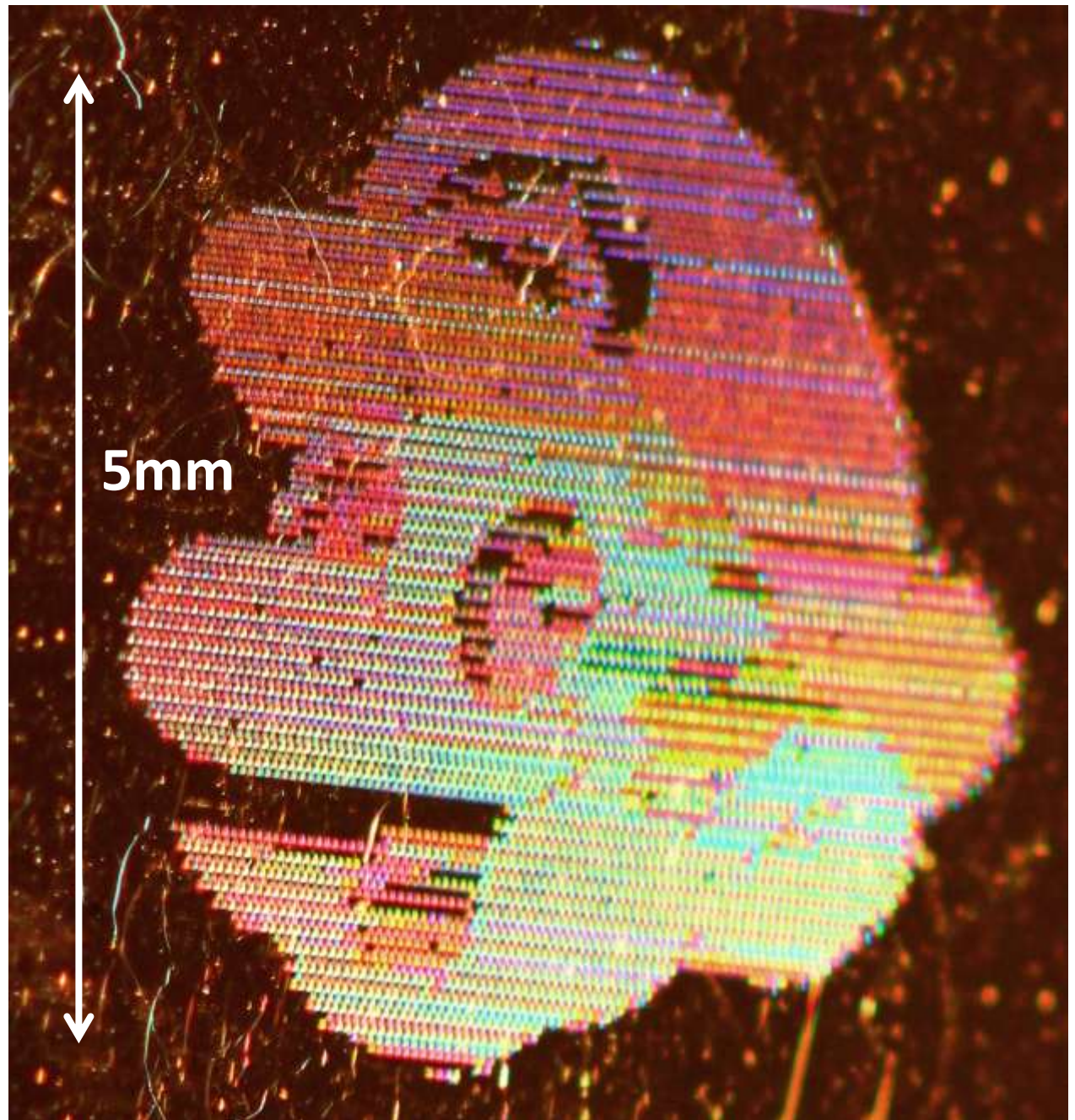
Each line 17 pixels wide

4.5x3.5mm total area, each pixel in image a grating of 30x30 $\mu$ m





Any image can be displayed on DMD for each pixel of course, not just gratings (though they look macroscopically attractive).

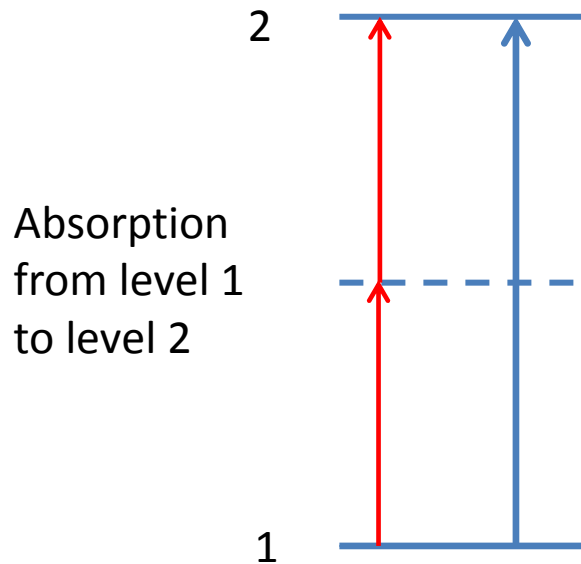


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# MPP

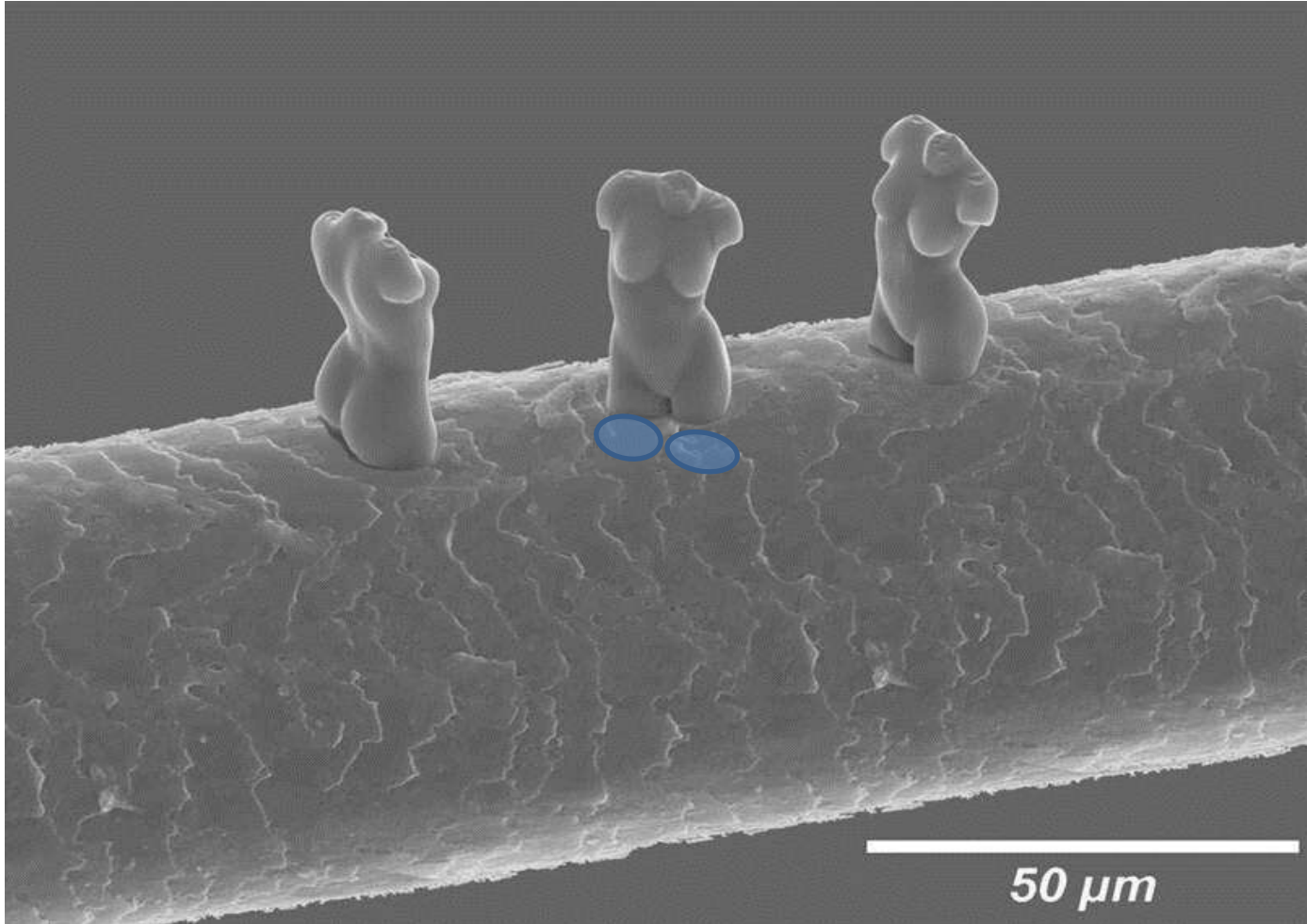
- With very fast laser pulses, materials can absorb at wavelengths they are '*not supposed to*'!
- Using light at 800nm wavelength, a material can simultaneously absorb 2 photons, equivalent to an absorption in the blue (400nm).



2 photons at 800 nm can have the same effect as 1 photon at 400nm.....very clever trick!



# Multiphoton writing (serial printing)

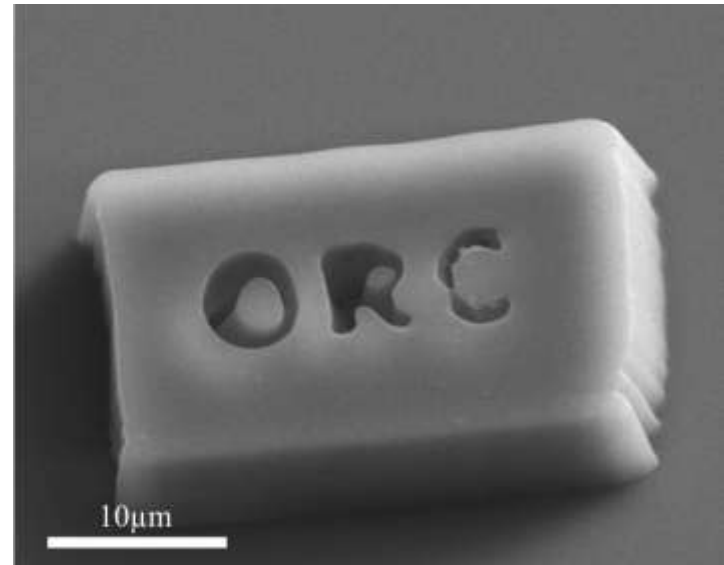


Laser Zentrum, Hannover, + Nanoscribe....many others

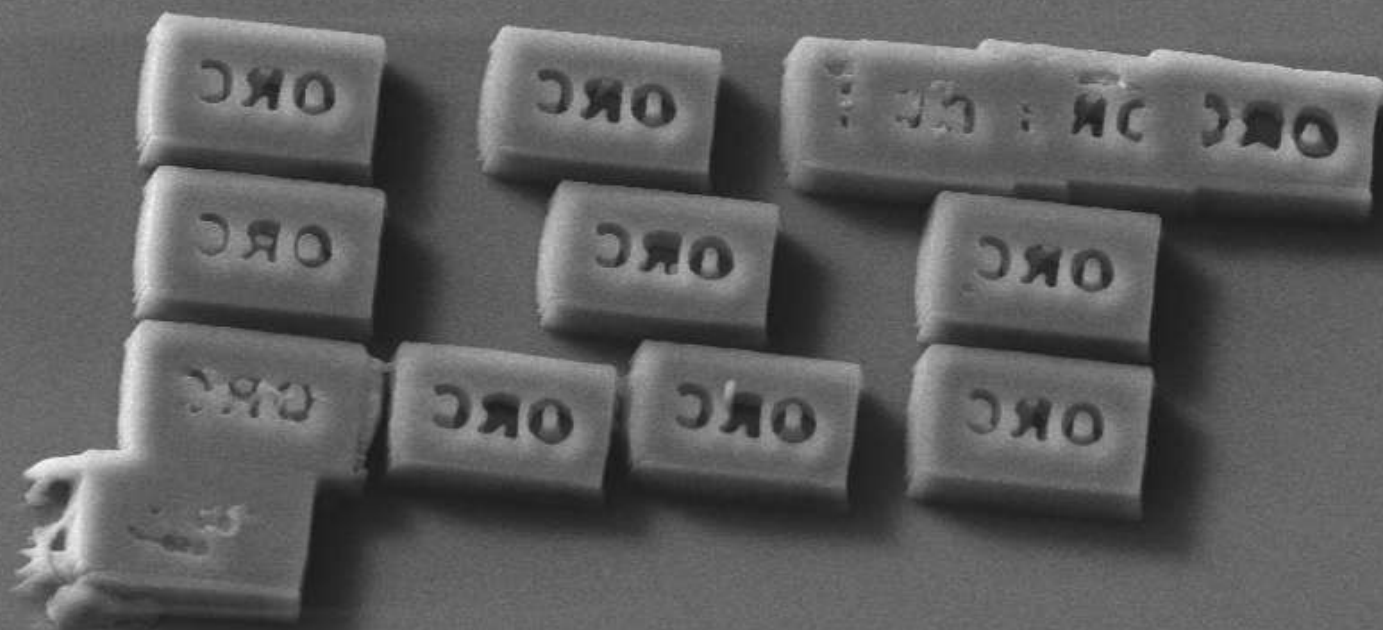
# DMD MPP but **single shot** exposure



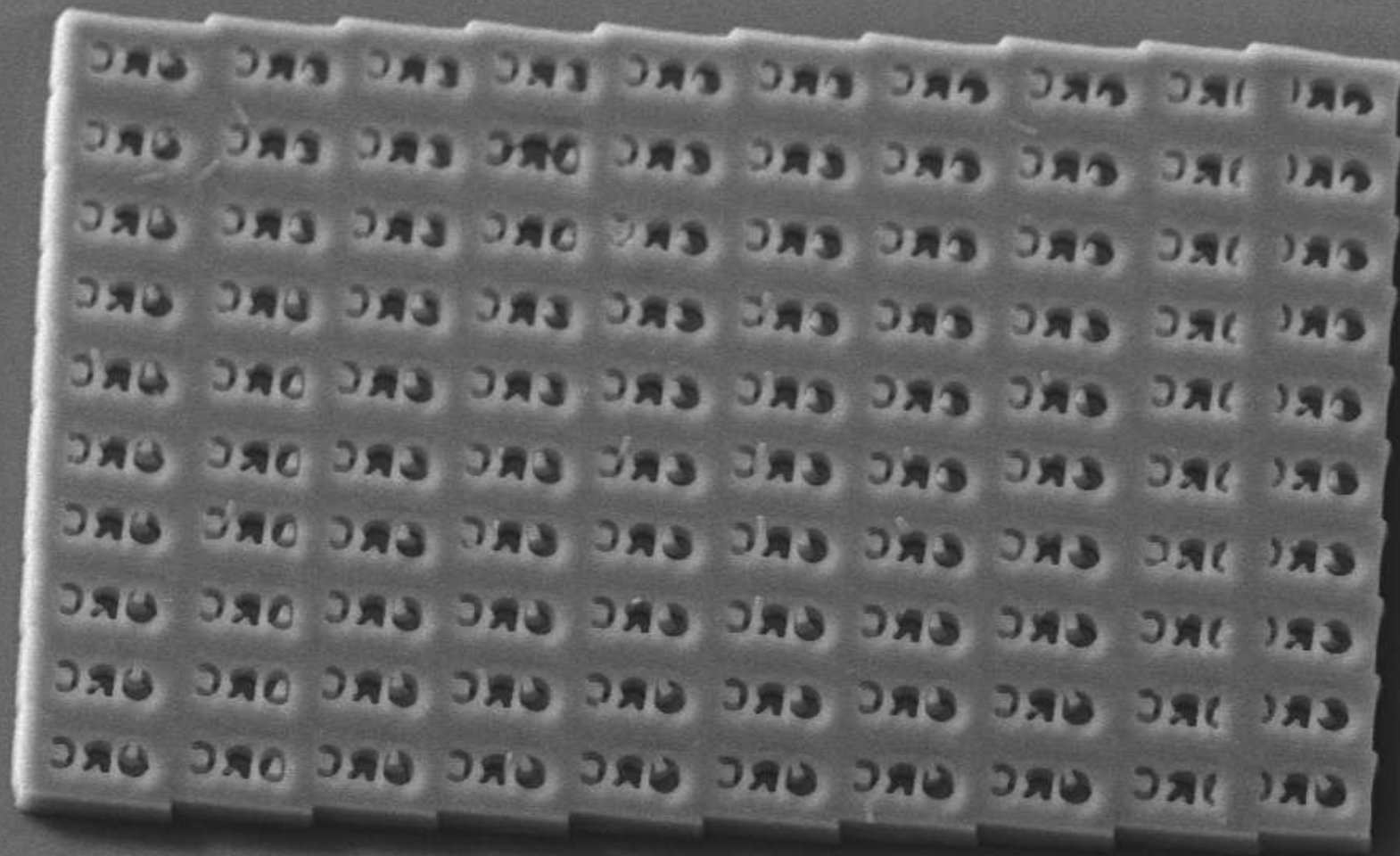
Image file that was displayed  
on the DMD during the  
period of the pulse



SEM image of structure  
fabricated using a single pulse





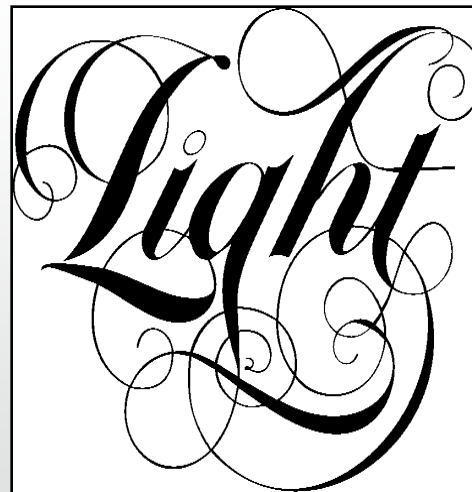
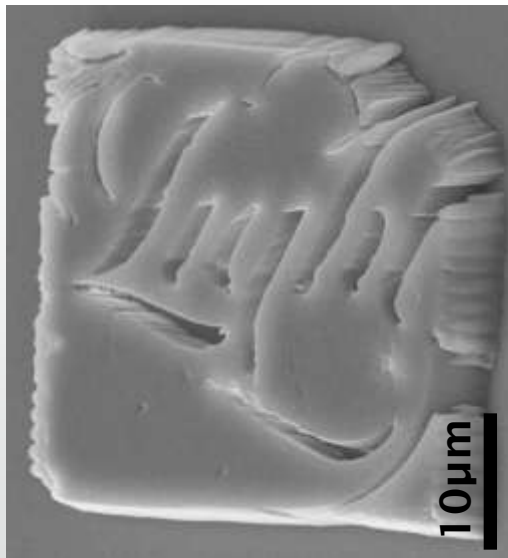


0.3 mm

## DMD-based approach

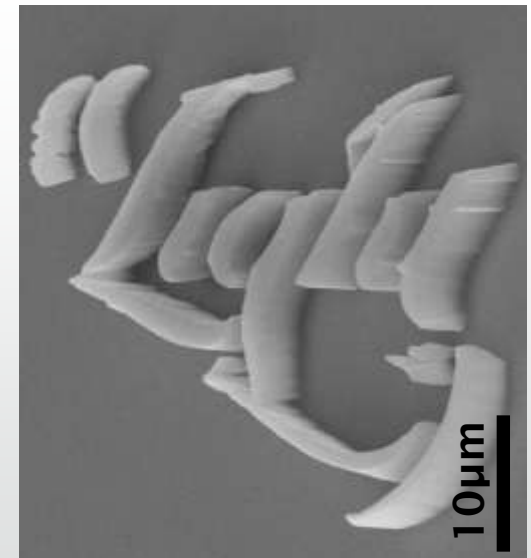
- For larger areas, maybe 10 shots is required for optimum definition:
- Feature size can be  $\sim 400\text{nm}$  ( $\sim \lambda/2$ )

+ contrast

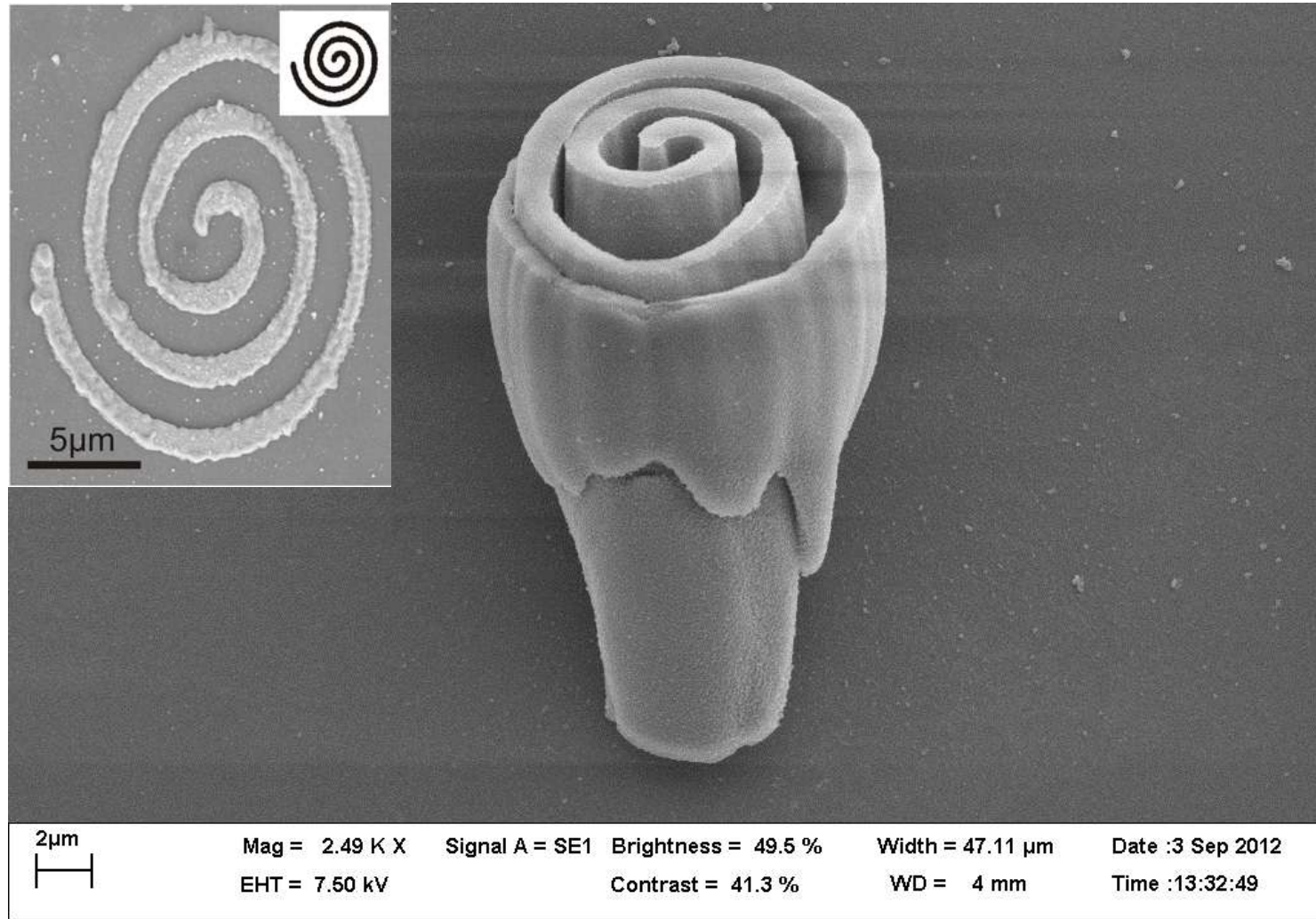


Pattern used on DMD

- contrast



# But need to consider depth of field



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# LIFT basics:

**Laser-Induced Forward Transfer = Laser printing**

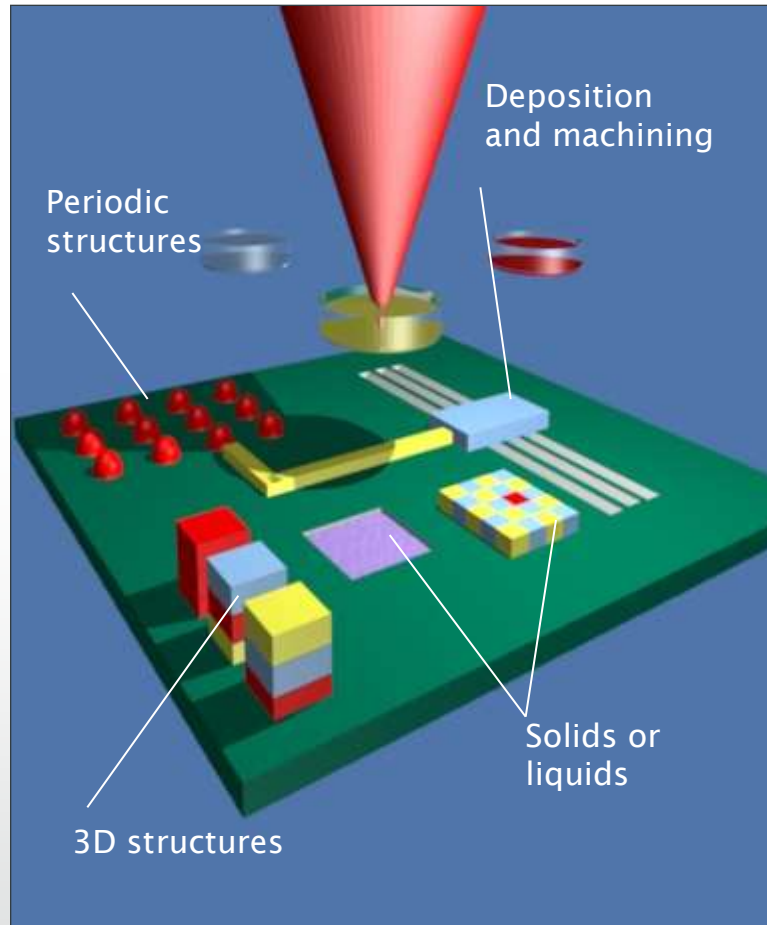


Typewriter	LIFT
Key	Laser
Ribbon	Carrier
Ink	Donor
Paper	Receiver





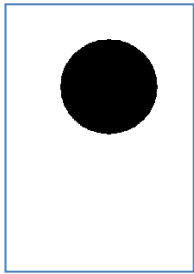
# LIFT – The Potential



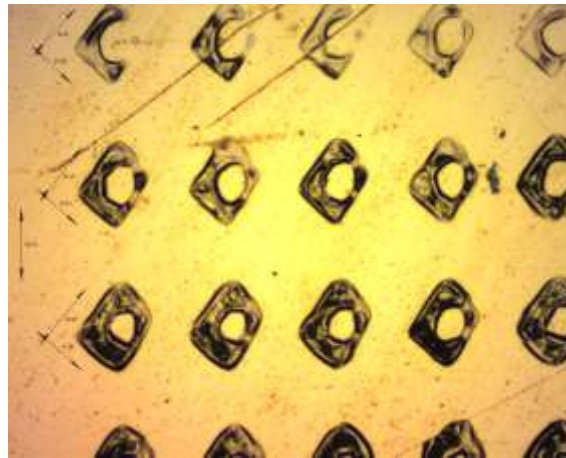
- Ultrashort regime → can ablate most source film materials.
- Deposition onto wide range of receiver materials and geometries.
- Fast and relatively simple.



## Using DMD patterning for incident laser field

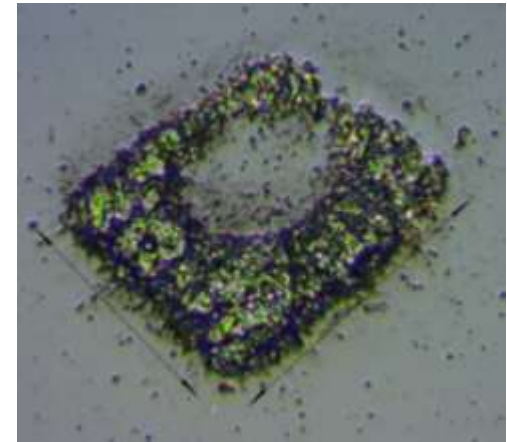


Pattern  
on the  
DMD



Pattern on the  
donor film

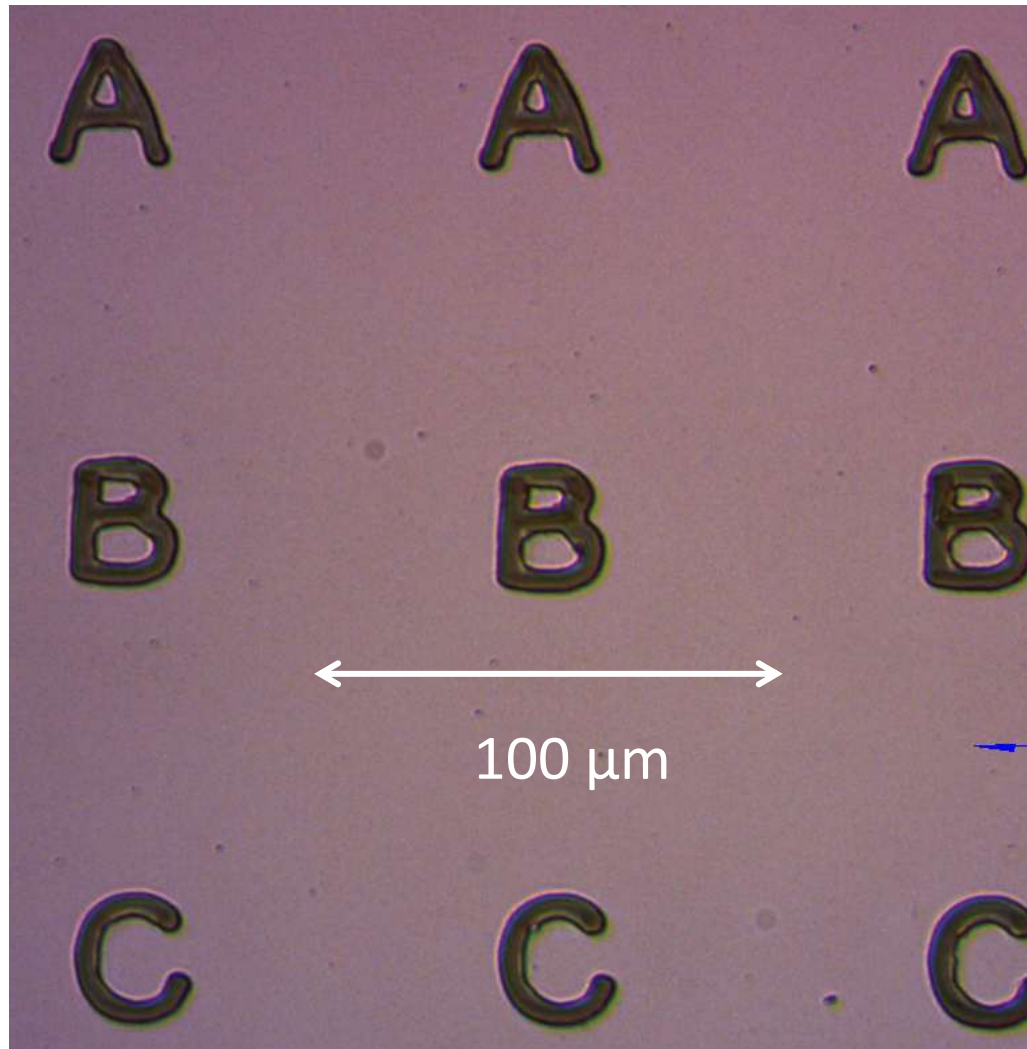
40 $\mu$ m x 40 $\mu$ m



Final LIFTed  
feature (Au on Si).

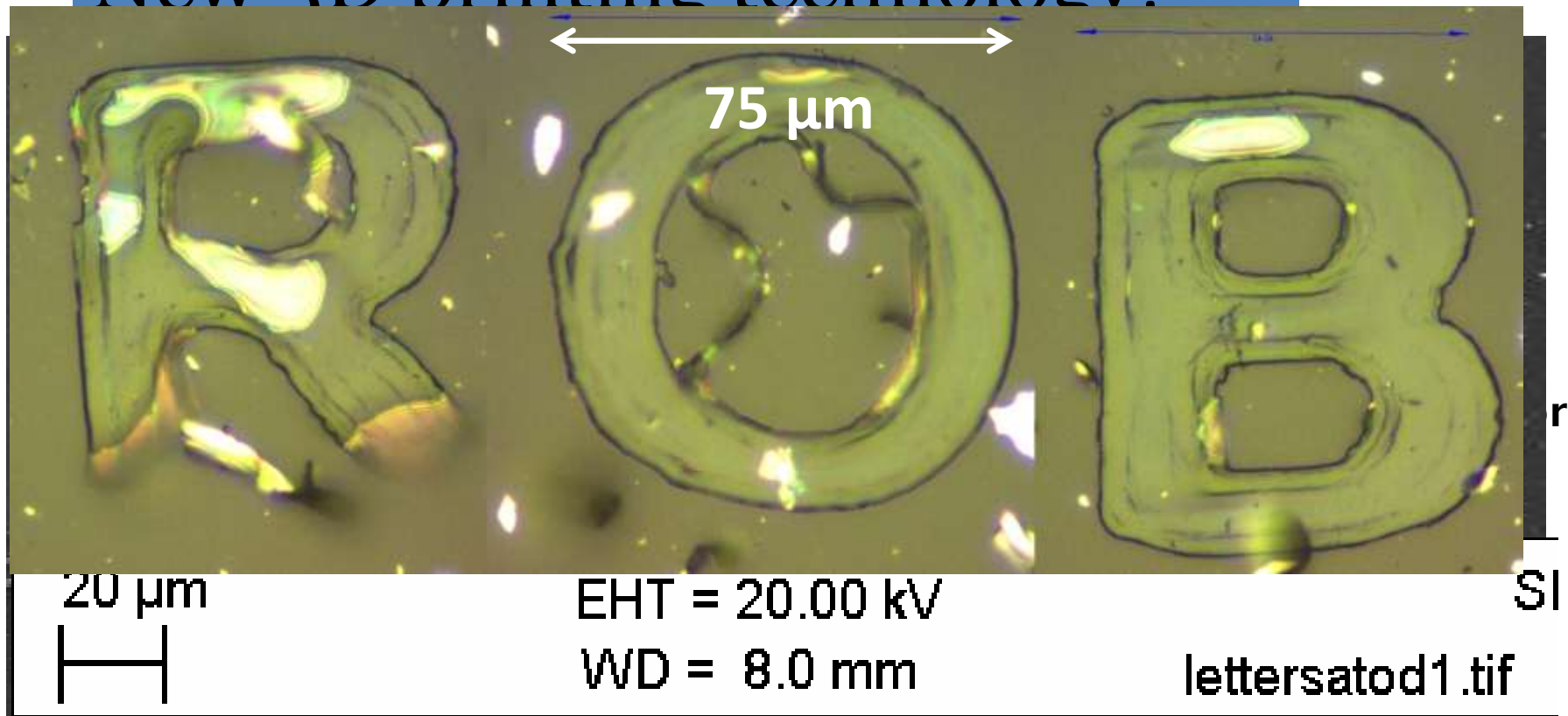


# 700nm thick Si films: the donor



# Most recent DMD LIFT results

New 3D printing technology!



# Summary

- DMDs are very useful for precise ablation, multiphoton polymerisation and LIFT and can produce  $\mu\text{m}$ -mm scale features.
- Single-shot processing and areas up to  $\sim 50 \mu\text{m}^2$
- Step and repeat for larger areas.

# Recent EPSRC grant announcement

- EP/L022230/1 : 2014/2015
- Digital Multimirror Devices for laser-based Manufacturing
- Under the *Manufacturing with light* scheme
- Please make contact with me via:

***rwe@orc.soton.ac.uk***